······	Application No.	Applicant(s)	
			(Age)
Notice of Allowability	10/747,824 Examiner	DIANA ET AL. Art Unit	— (IV
·			
	Trung Dang	2823	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85; NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31;	(OR REMAINS) CLOSED in or other appropriate commu IGHTS. This application is s	this application. If not include inication will be mailed in due c	d course. THIS
1. X This communication is responsive to amendment after fine	al filed 8/19/05.		
2. X The allowed claim(s) is/are 1-15,17-20 and 22-26.			
 Acknowledgment is made of a claim for foreign priority u a) ☐ All b) ☐ Some* c) ☐ None of the: 	nder 35 U.S.C. § 119(a)-(d) o	or (f).	
 Certified copies of the priority documents have 	e been received.		
2. Certified copies of the priority documents have	e been received in Applicatio	n No	
Copies of the certified copies of the priority do	cuments have been received	d in this national stage applicati	on from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		a reply complying with the requ	uirements
 A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which giv 			OTICE OF
5. CORRECTED DRAWINGS (as "replacement sheets") mu	st be submitted.		
(a) ☐ including changes required by the Notice of Draftsper		v (PTO-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date	<u>.</u> .		
(b) including changes required by the attached Examiner Paper No./Mail Date	's Amendment / Comment or	in the Office action of	
Identifying indicia such as the application number (see 37 CFR areach sheet. Replacement sheet(s) should be labeled as such in			back) of
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 			ote the
Attachment(s)	E □ Nation of Im	formal Datant Application (DTO	152)
1. Notice of References Cited (PTO-892)	-	formal Patent Application (PTO ummary (PTO-413),	-132)
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	Paper No./	Mail Date Amendment/Comment	
Information Disclosure Statements (PTO-1449 or PTO/SB/Paper No./Mail Date Paper No./Mail Date Pagarding Requirement for Deposit		Statement of Reasons for Allov	wance
Examiner's Comment Regarding Requirement for Deposit of Biological Material	<u> </u>	Citatement of freesons for Alloy	TUITOC
	9.	Trung Dang Primary Examiner Art Unit: 2823	

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Briski on August 26, 2005.

IN THE CLAIMS

Claim 13: Change claim 13 as follows:

A ferroelectric polymer die, comprising:

a silicon (Si) substrate;

an oxide thermal insulation layer on top of the Si substrate;

a first metal layer on top of the oxide layer;

a ferroelectric polymer on top of the first metal layer;

an interlevel dielectric (ILD) layer on top of the ferroelectric polymer layer;

a second metal layer on top of the ILD layer; and

a via metal fill plug passing through the ILD layer and the ferroelectric polymer

layer to electrically connect the first metal layer to the second metal layer,

wherein the second metal layer has a thickness in the range of 20 nanometers to

100 nanometers.

Application/Control Number: 10/747,824 Page 3

Art Unit: 2823

Claim 17: Change the dependency of claim 17 to claim 15.

Add new claim 26 as follows:

The ferroelectric polymer die of claim 20, wherein the interlayer via plug is formed by an electroless plating process.

Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance:

Claims 1-12 and 22-25 are allowed over prior art of record for the same reasons indicated in previous Office action.

Claim 13 and its dependent claims are allowable over prior art of record because the prior art does not teach or suggest a ferroelectric polymer die structure as claimed, which includes a second metal layer having a thickness in the range of 20 nanometers to 100 nanometers. In the Johnson reference cited in previous rejection, metal layer 40 (Fig.10) was interpreted to read on the claimed second metal layer. However, the thickness of metal layer 40 is approximately equal the thickness of ILD 36 which is from about 0.5 to 5.0 microns (para. [0058]). It would have been unobvious as to why one skilled in the art would be motivated to select the thickness of metal layer 40 in the range as claimed because the difference between the claimed range and the disclosed range is so large that modification would be unreasonable.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably Application/Control Number: 10/747,824

Art Unit: 2823

accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is 571-272-1857. The examiner can normally be reached on Mon-Friday 9:30am-6:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Trung Dang
Primary Examiner

Page 4

Art Unit 2823

08/27/05